

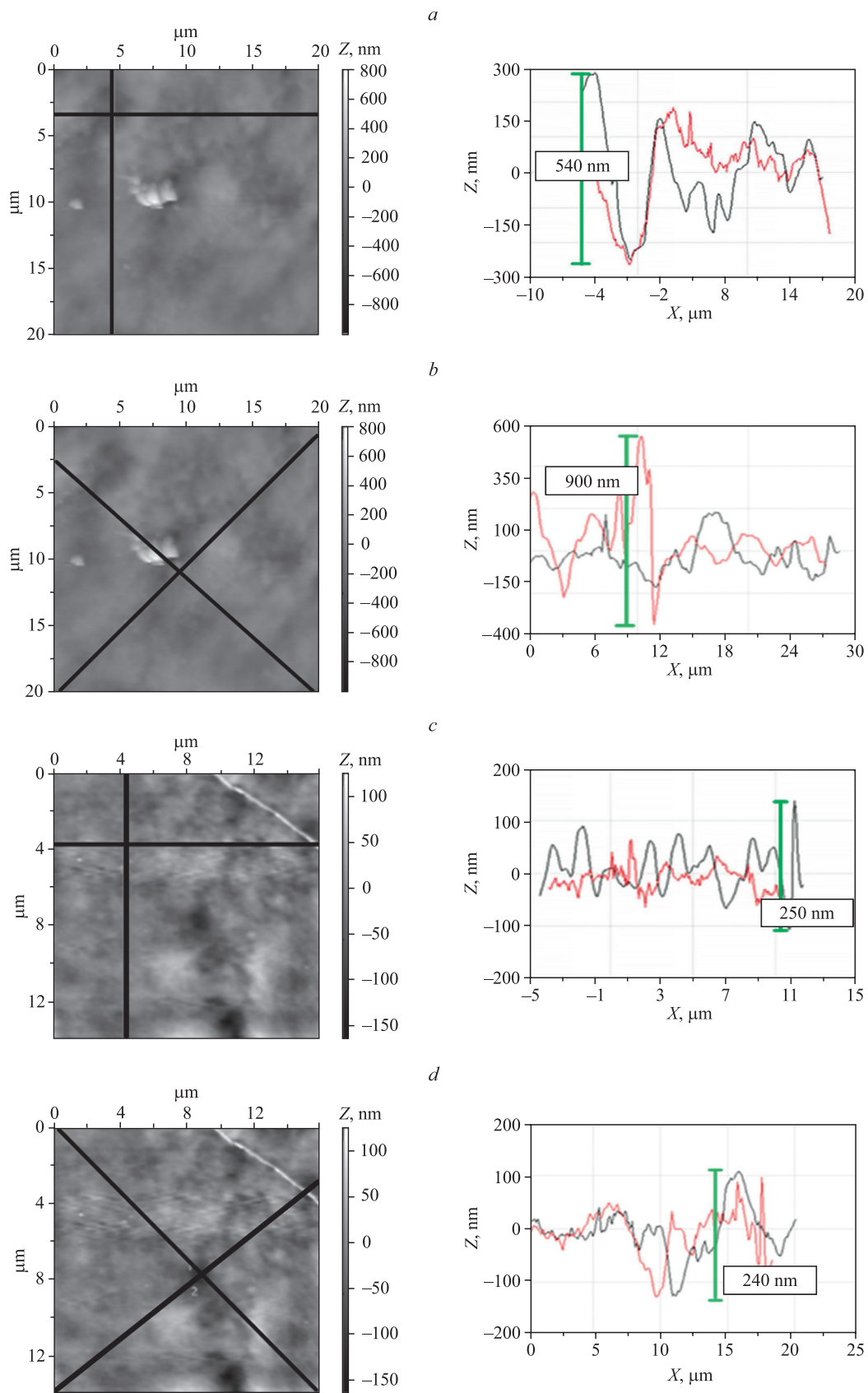


Fig. 2. AFM images and surface relief profiles of $\text{V}_2\text{O}_5 : \text{MoO}_3$ films exposed to UV-light (a, b) and exposed to UV-light and etched in acid solution for 6 min (c, d). The profiles were obtained in the normal directions (a, c) and in the diagonal directions (b, d)